## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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2/15/03

Name of Person Making the Deposit:

Judy Davenport

Signature of the Person Making the Deposit:

Inventor(s):

Fan Zhong, Jonathan G. Bornstein

Serial No.:

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Group Art Unit:

1731

Filed:

06/04/01

Examiner:

Fortuna, Jose A.

Confirmation No: 5827

Title:

HIGH-DENSITY PLASMA DEPOSITION PROCESS FOR FABRICATING A TOP

CLAD FOR PLANAR LIGHTWAVE CIRCUIT DEVICES

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

## TRANSMITTAL OF FORMAL DRAWINGS

In response to Drawing Informalities

attached please find:

X | (a)

the formal drawings for this application

Number of Sheets

Each sheet of drawing indicates the identifying indicia suggested in § 1.84(c) on the

reverse side of the drawing

a copy of the NOTICE OF INFORMAL DRAWINGS

Please direct all correspondence concerning the above-identified application to the following address:

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Respectfully submitted,

By:

Glenn D. Barnes

Reg. No. 42,293